Unique Source for Space Microelectronics

- → 130 nm/250 nm SiGe BiCMOS
- → 8" (200 mm) Wafer Processing Pilot Line
- Advanced Design Kits Digital and Mixed-Signal for ASIC and MMIC design
- Radiation Tolerant / Radiation Hard IPs
- Technology for Harsh Environments
- Multi Project Wafer Service IC Prototyping
- **→** Low Volume Production
- Design Support

ABOUT IHP

IHP is a non-profit organization supported by the authorities of the state of Brandenburg and the German Federal government that performs R&D in the field of silicon-based systems, highest-frequency ICs and technologies for wireless and broadband communications especially suited for applications in the highest GHz band thanks to integrated HBT devices with high cut-off frequencies of up to 500 GHz Manufacturing and Value Added Services for commercial IC production are provided via IHP Solutions GmbH, a fully-owned subsidiary of IHP under private law.

OUR STRENGTHS

- IP design, back-end and integration
- Process or device characterization
- Silicon evaluation



We design your circuits based on available IPs in IHP's technologies!



IHP – Leibniz- Institute for High Performance Microelectronics

Im Technologiepark 25 15236 Frankfurt (Oder)

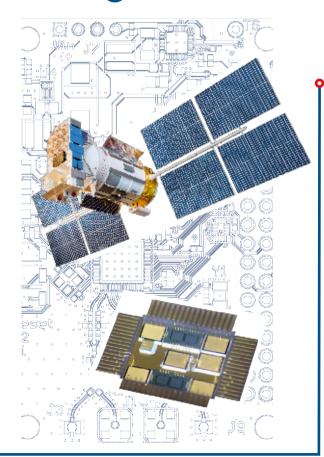
www.ihp-microelectronics.com, ihp@ihp-microelectronics.com

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scholz@ihp-microelectronics.com





Radiation Hard Design Kit





Overview

IHP offers research partners and customers access to its powerful SiGe: C BiCMOS technologies and special integrated RF modules.

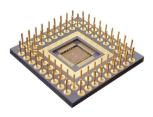
These technologies are especially suited for applications in the higher GHz bands (e.g. for wireless, broadband, radar).

LIBRARIES AND IPS

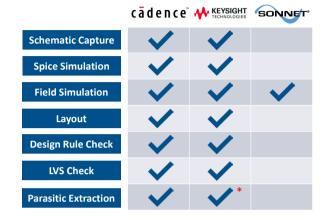
- Extended Operating Temperature Range : -55° C to +125° C
- MOS special layouts (ELT, SLT, JIC)
- MIM Capacitors, MOS Varactors, Inductor Models

Radiation Tolerant Libraries Radiation Levels:

- → Bipolar (HBT) Devices TID > 800 krad
- **-○** CMOS TID levels 100 krad(Si) 300 krad(Si)
- **-○** CMOS SEU Threshold > 35MeV.cm²/mg -
- CMOS Special Cells SEU Threshold > 65 MeV. cm²/mg
- → SEL Free > 65 MeV.cm²/mg



Supported EDA Tools for RH PDKs



SIGE BICMOS PROCESS CAPABILITY

SGB25RH	SG13RH		
250nm SiGe BiCMOS	130nm SiGe BiCMOS		
SiGe HBTs npn	SiGe HBTs npn		
Peak f _T /f _{MAX} 75/95GHz	Peak f _T /f _{MAX} 220/340GHz		
Mixed-Signal MMIC/ASIC up to Ku-Band	Mixed-Signal MMIC/ASIC up to Ka-Band		
+2.5 V CMOS Core Voltage	+1.2 V CMOS Core Voltage		
+2.5 V/+3.3 V Digital	+2.5 V/+3.3 V Digital		
IO Pads	IO Pads		

MODELING

	Туре	scalable	mismatch	statistical	noise	RF
NPN	VBIC HiCUM	V	V	V	V	V
MOSFET	PSP	V	V	V	V	V
Varactor	PSP MOSVAR	V	V	V	V	V
MIM Caps	SPICE	V	V	V		V
Resistors	SPICE	V	V	V	V	V
Inductors	S-Param					V

Services

CMOS DIGITAL BACK-END

- Synthesis, Place & Route, Parasitic Extraction
- Research & Development of RHBD techniques
- Device Modeling
- TID Device Characterization
- SEU Testing with External Partners

EPPL REGISTERED



Listed on European Preferred Parts List

- SGB25RH validated & listed
- **-○** SG13RH is under evaluation process
- Extended life time endurance tested
- Component Standardisation Section at ESA
- European Space Components Coordination
- Supporting innovative technologies while maintaining quality assurance requirements

MODULES

Special Modules offered for R&D

- Radiation Hardened LDMOS
- Embedded RF-MEMS



